

Feature

- •Precision MEMS process
- •High performance, shielded, Micro-cavity structure
- •Silicon substrate, 50Ω CPW output
- •Au wire bonding, for MCM applications

Environmental Specifications

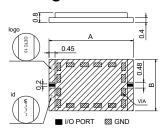
Operating Temperature	-55°C~+85°C		
Storage Temperature	-55℃~+125℃		
Max. Input Power	35dBm		

Electrical Specifications(T_A=+25°C)

Parameter	Min.	Тур.	Max.	Unit
Center Freq. (f ₀)	-	10	-	GHz
Pass Band	8	-	12	GHz
Ripple in Pass band	-	-	1	dB
Insertion Loss @ f ₀	-	-	1.5	dB
Return Loss	15	-	-	dB
	≥30@7.23GHz &13.16GHz			dB
Out of band	≥40@	dB		
Attenuation	≥60@DC-6.18GHz			dB
	≥60@14.2-18.3GHz			dB
Group Delay Variation	≤0.7@8-12GHz			ns
Linear Phase	≤±26@	۰		

S2P file name: SiMF10_4-9D1.s2p

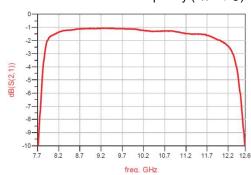
Outline Drawing



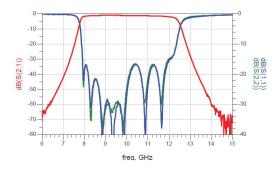
Symbol	Value (mm)				
	Min.	Nominal	Max.		
Α	6.9	-	7.0		
В	3.1	-	3.2		

Typical Test Curves

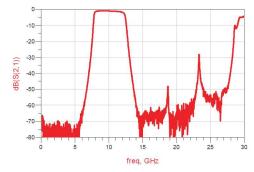
Insertion Loss VS Frequency (T_A=25°C)



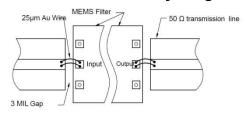
Insertion Loss & Return Loss VS Frequency (T_A=25°C)



Broadband Insertion Loss VS Frequency (T_A=25°C)

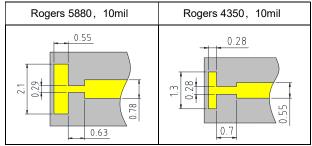


Recommended Assembly Diagrams



Application Notes:

- 1. The chip is back-metalized and can be die mounted with AuSn eutectic performs or with electrically conductive epoxy (for example ME8456).
- 2. The die should be assembled on carriers like Kovar or Mu-Cu which have same Coefficient of thermal expansion. (2.9ppm/ $^{\circ}$ C) with Silicon, thickness 0.2mm max.
- 3. Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.
- 4. Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers.
- 5. Recommended to use T structure as below for bonding.



6. If you have any questions, please contact us.